

UNITED STATES PATENT AND TRADEMARK OFFICE



APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/652,714	08/31/2000	Vishnu K. Agarwal	98-0616.09	3982	
27076 7	7590 01/02/2002				
DORSEY & WHITNEY LLP SUITE 3400 1420 FIFTH AVENUE			EXAMINER		
			DIAZ, JOSE R		
SEATTLE, WA 98101			ART UNIT	PAPER NUMBER	
			2815		
			DATE MAILED: 01/02/2002	DATE MAILED: 01/02/2002	

Please find below and/or attached an Office communication concerning this application or proceeding.

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Office Action Summary		Application No.	Applicant(s)			
		09/652,714	AGARWAL, VISHNU K.			
		Examiner	Art Unit			
	The MAILING DATE of this communication and	José R. Díaz	2815			
	The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for R ply					
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). Status						
1)⊠	Responsive to communication(s) filed on 17 C	October 2001 .				
2a)⊠		s action is non-final.				
3)	· · ·					
Disposition of Claims						
4)⊠ Claim(s) <u>36-39 and 76-85</u> is/are pending in the application.						
4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>36-39 and 76-85</u> is/are rejected.						
7)	Claim(s) is/are objected to.					
8) Claim(s) are subject to restriction and/or election requirement.						
Application Papers						
9) The specification is objected to by the Examiner.						
10) The drawing(s) filed on is/are: a) □ accepted or b) □ objected to by the Examiner.						
	Applicant may not request that any objection to the					
11)∐ T	he proposed drawing correction filed on		oved by the Examiner.			
If approved, corrected drawings are required in reply to this Office action.						
12) The oath or declaration is objected to by the Examiner.						
Priority under 35 U.S.C. §§ 119 and 120						
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a) All b) Some * c) None of:						
1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents have been received in Application No						
 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 						
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).						
a) ☐ The translation of the foreign language provisional application has been received. 15)☑ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.						
Attachment(s)						
2) Notice	of References Cited (PTO-892) of Draftsperson's Patent Drawing Review (PTO-948) ation Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of Informal	y (PTO-413) Paper No(s) Patent Application (PTO-152)			

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DETAILED ACTION

Claim Rejections - 35 USC § 103

- ➤ The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- ➤ Claims 36-39 and 76-85 are rejected under 35 U.S.C. 103(a) as being unpatentable over Applicant's Specification in view of Agarwal et al. (US Pat. No. 6,201,276 B1).

Regarding claims 36, 76 and 81, Applicant acknowledges that is well known in the art a method of forming a device (see Figures 1-3 and 6-8) comprised of the steps: forming a first conductive of tungsten nitride (28, 52) and a second conductive (30, 48) and exposing the second conductive to a thermal process (see Figures 2-3 and 7-8, page 6, lines 4-12 and page 11, lines 1-9 of Applicant's Specification). However, Applicant fails to disclose incorporating an oxygen-free material into the tungsten nitride. Agarwal et al. teach a well-known method wherein the tungsten nitride is annealed to form a protective barrier (see col. 4, lines 40-67, col. 5, lines 64-67 and col. 6, lines 1-10). Therefore, it would have been obvious to one having ordinary skill in the art at the same time the invention was made to modify Applicant's Specification to include the step of incorporating an oxygen-free material into the tungsten nitride. The ordinary artisan would have been motivated to modify Applicant's Specification in the manner

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described above for at least the purpose of reducing the current leakage in the capacitor.

Regarding claims 37, 77 and 82, Applicant acknowledges that it is well known in the art to form and flow an insulator (34) over the second conductive layer (30) (see Fig. 3).

Regarding claims 38, 79 and 84, Applicant acknowledges that it is well known in the art to deposit a plug (46) and to flow the second conductive layer (48) (see Figures 7-8).

Regarding claims 39, 80 and 85, Applicant acknowledges that it is well known in the art that the thermal process comprises exposing said second conductive layer to an alloy process (see page 11, lines 1-3 of Applicant Specification).

Regarding claims 78 and 83, Applicant acknowledges that the second conductive layer (48) comprises copper (see page 10, lines 19-20).

Response to Arguments

➤ Applicant's arguments with respect to claims 36-39 and 76-85 have been considered but are most in view of the new ground(s) of rejection.

Conclusion

> The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Narwankar et al. (US Patent No. 6,204, 203 B1) disclose post

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deposition treatment of dielectric films for interface control. Lu et al. (US Patent No. 5,913,145) disclose passivating a tungsten nitride layer (see Figures 1A-1E).

➤ Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Correspondence

Any inquiry concerning this communication or earlier communications from the examiner should be directed to José R. Díaz whose telephone number is (703) 308-6078. The examiner can normally be reached on 8:00 - 5:00 Monday through Fridays.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie C. Lee can be reached on (703) 308-1690. The fax phone numbers

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for the organization where this application or proceeding is assigned are (703) 308-7722 for regular communications and (703) 308-7722 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

JRD December 26, 2001

> SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2800